

ELBE.

Robust Mg cathodes in SRF gun-II

Rong Xiang on behalf of the SRF Gun Group

1 EWPA 2019, 11 Sep. - 13 Sep. 2019, PSI



hzdr

HELMHOLTZ
ZENTRUM DRESDEN
ROSSENDORF

Outline

1. Status of ELBE SRF gun-II
2. Mg photocathodes in SRF gun-II
3. ps UV laser cleaning of Mg photocathodes
4. Alternative preparation methods of Mg
5. Summary and outlook





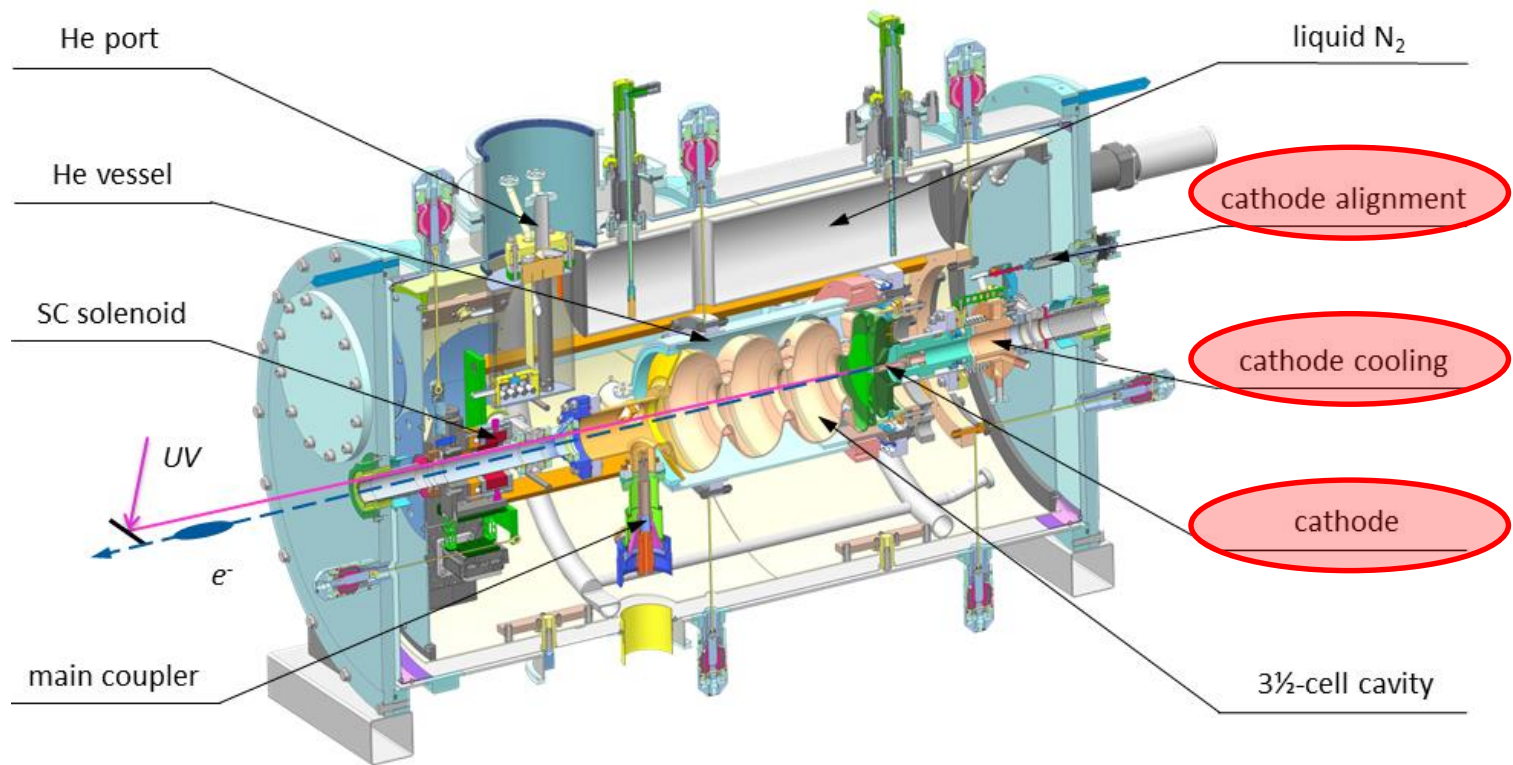
1. Status of ELBE SRF gun-II

	Milestone of cathode in gun
Jun. 2010	cavity manufacture finish in Jlab
Aug. 2014	commissioning at HZDR
Feb. 2015	first CW beam with Cu cathode
Nov. 2016	Mg cathode in operation
Mar./Jun. 2017	Cs ₂ Te (Mo) in gun
Since 2017	stable operation with Mg



SRF Gun-II in ELBE hall

1. Status of ELBE SRF gun-II



parameters of SRF gun II in operation

$E_{\text{acc}} = 8 \text{ MV/m CW (20 MV/m peak field on axis)}$

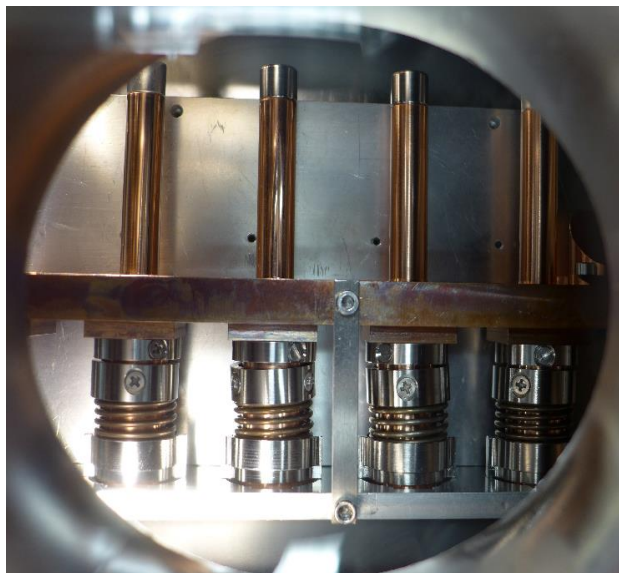
$E_{\text{cathode}} = 12 \text{ MV/m (field on cathode)}$

$I_{\text{dark}} \sim 30 \text{ nA @8 MV/m}$

4 MeV kinetic energy, bunch charge < 0.4 nC

1. Status of ELBE SRF gun-II

Keyword: NC cathode for SC cavity



Semiconductor photocathodes

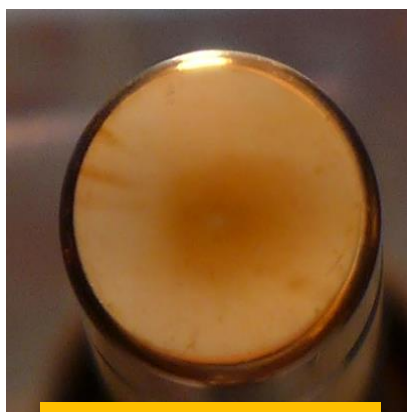
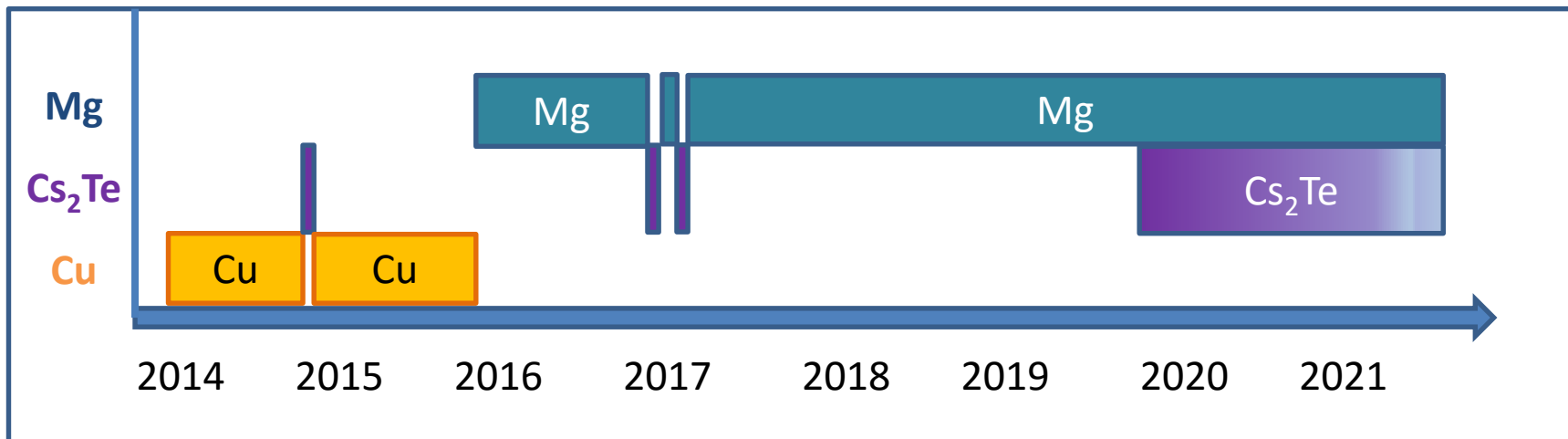
- high risk of contamination
- vacuum demanding
- preparation system
- high quantum efficiency (QE)
- less laser power required

Metallic photocathodes

- good compatibility with Nb cavity
- robust, long lifetime
- fast response
- low QE
- high UV laser power required

1. Status of ELBE SRF gun-II

Cathodes applied in SRF Gun-II



Cu plug (used)



Cs₂Te on Mo plug

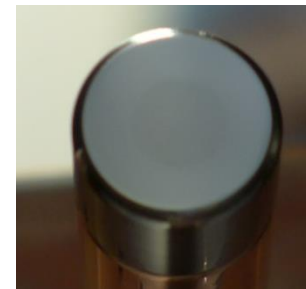
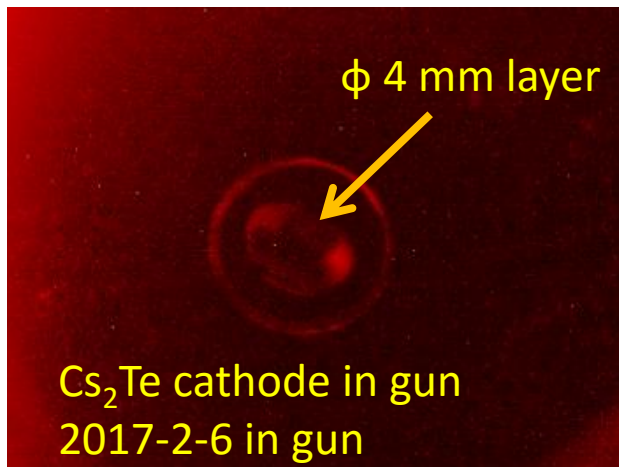


Mg pug #216

1. Status of ELBE SRF gun-II

Problem: cathode overheating in SRF gun II

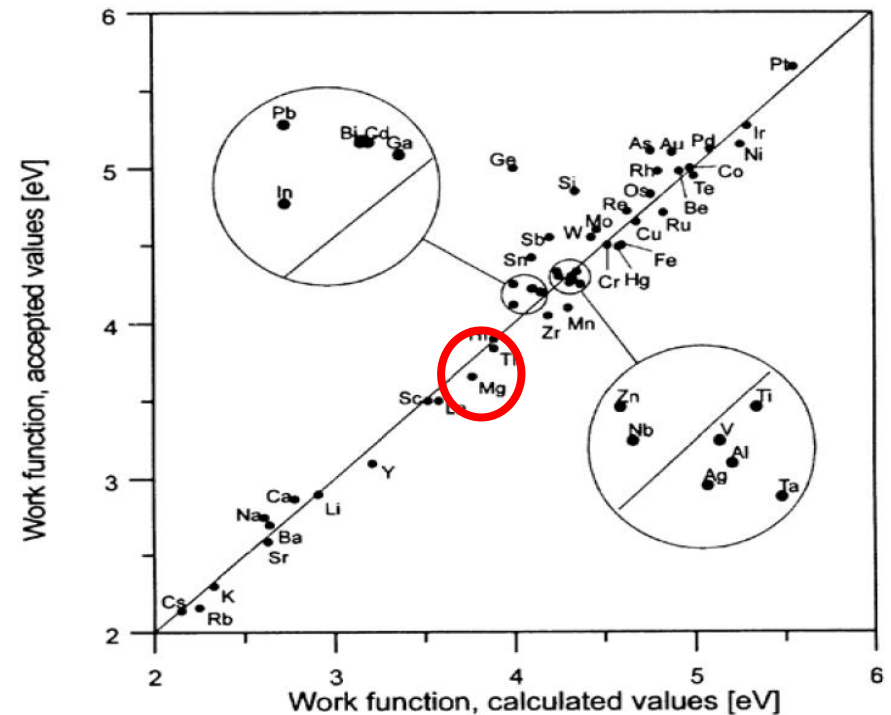
in 2017, Cs₂Te cathodes #2016.03, #2017.03 disappeared in SRF gun II, cavity is recovered by warming up - cooling down cycle.



2. Mg photocathodes in SRF gun-II

a „Clean“ (Cs-free) cathode for SRF gun

Metal (polycrystalline)	QE (%)	ϕ (eV)
Cu	$10^{-6} - 10^{-5}$	4.6
Mg	$10^{-6} - 10^{-4}$	3.6
Mo	10^{-6}	4.5
Nb	10^{-6}	4.3
Pb	10^{-6}	4.25



Lide, D. R.. Properties of Solids, in: *CRC Handbook of Chemistry and Physics, Internet Version 2005.*

Boca Raton, FL: CRC Press; 2005, P. 124

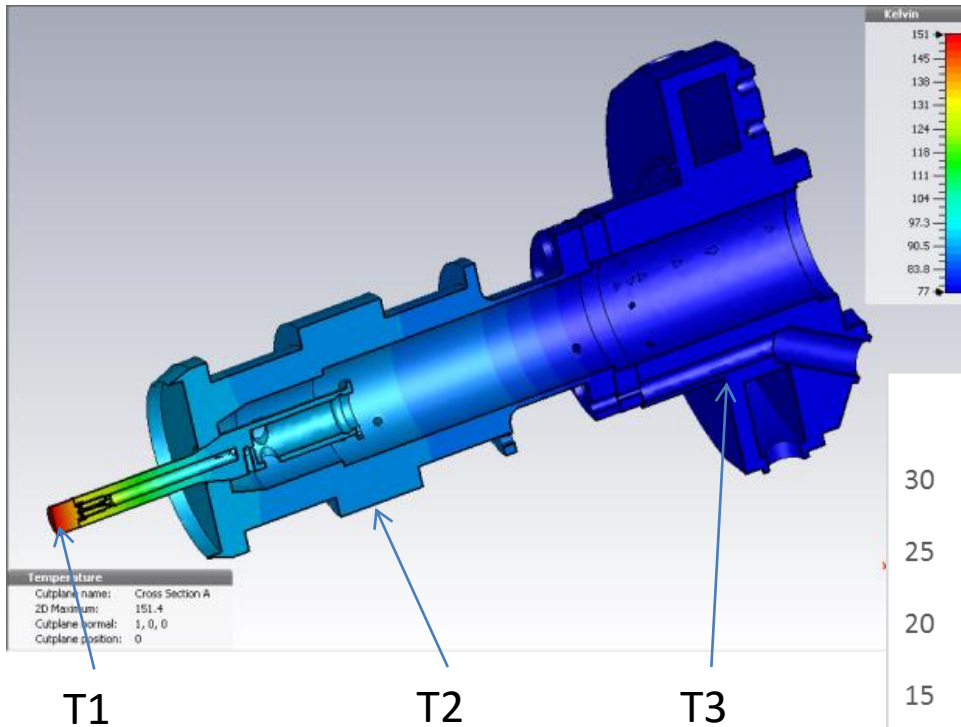
S. Halas, Materials Science-Poland, Vol. 24, No. 4, 2006

2. Mg photocathodes in SRF gun-II

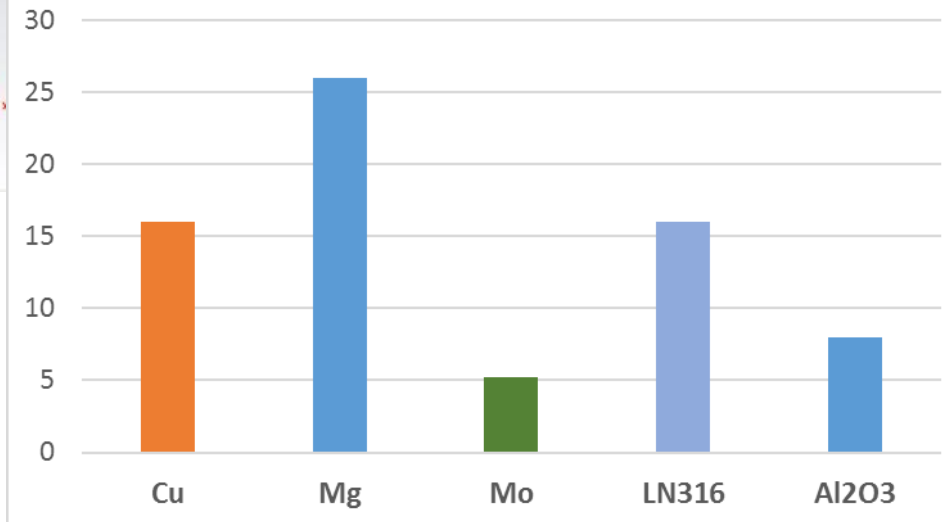
avoid overheating of cathode

thermal transition coefficient

(W/m.K)	@ room temperature	@ LN temperature
Cu	401	~ 500
Mo	138	~ 220
Mg	156	~ 200
Al ₂ O ₃	30	~ 200

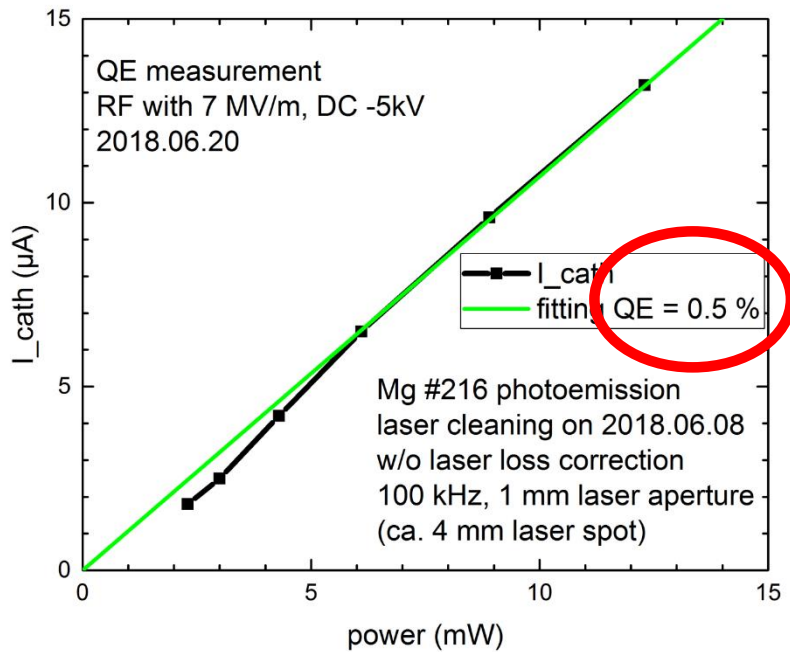


Thermal expansion coefficient

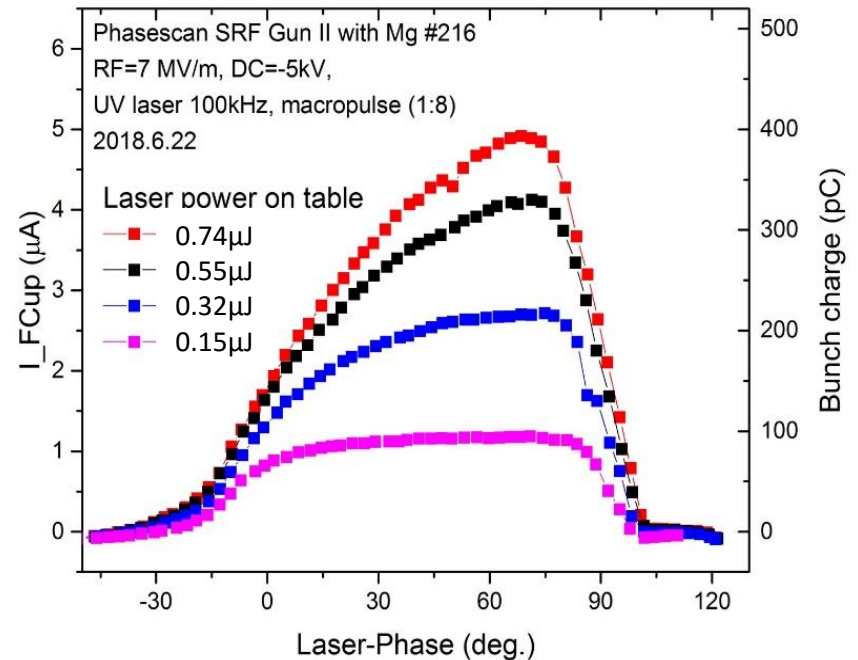


2. Mg photocathodes in SRF gun-II

✓ High QE @ 258nm
after laser cleaning



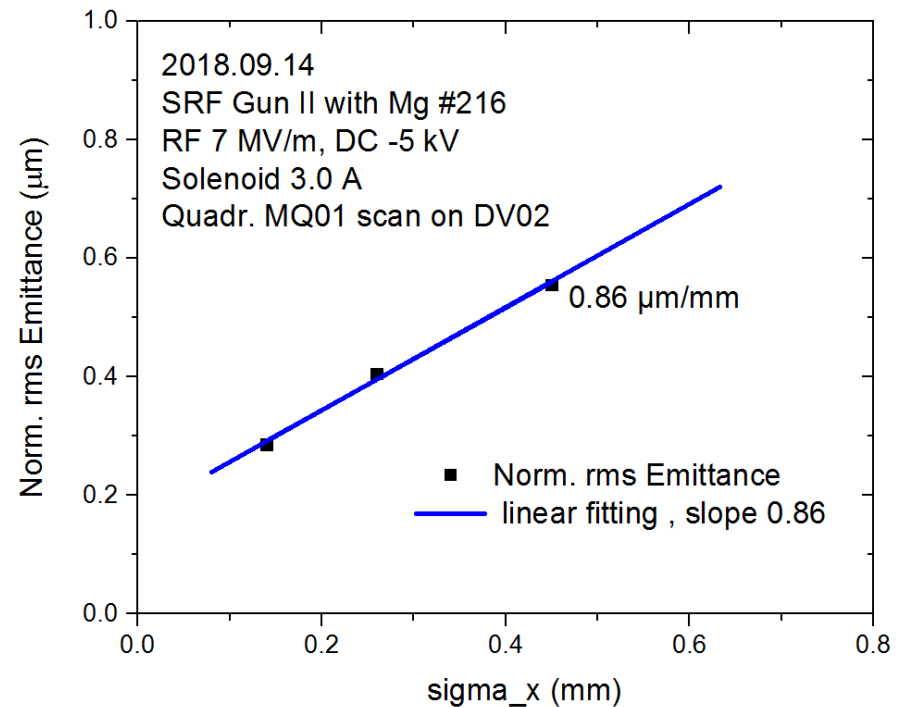
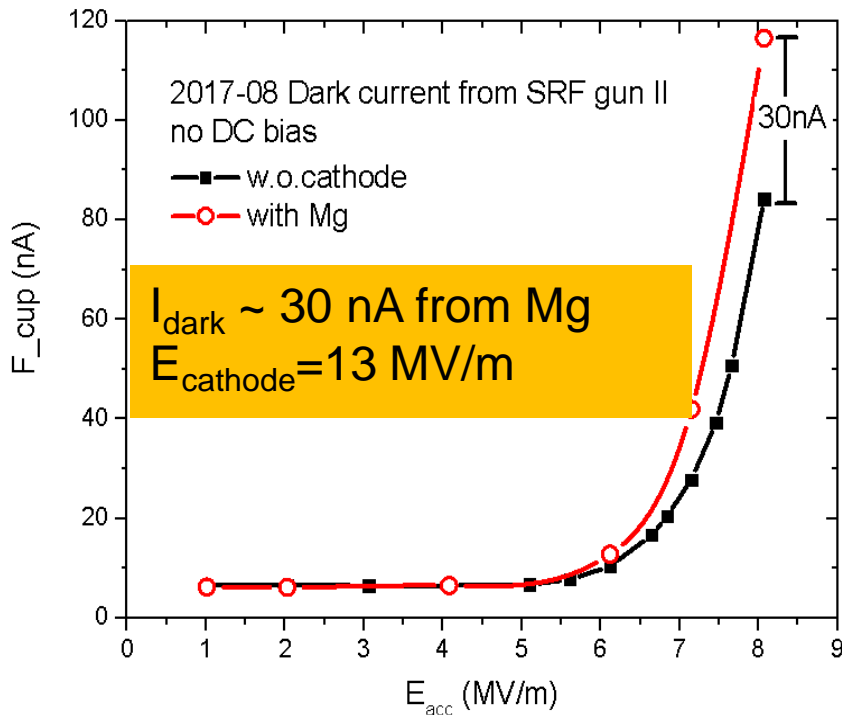
✓ Bunch charge ~ 0.3 nC



2. Mg photocathodes in SRF gun-II

- ✓ No multipacting problem
- ✓ acceptable dark current

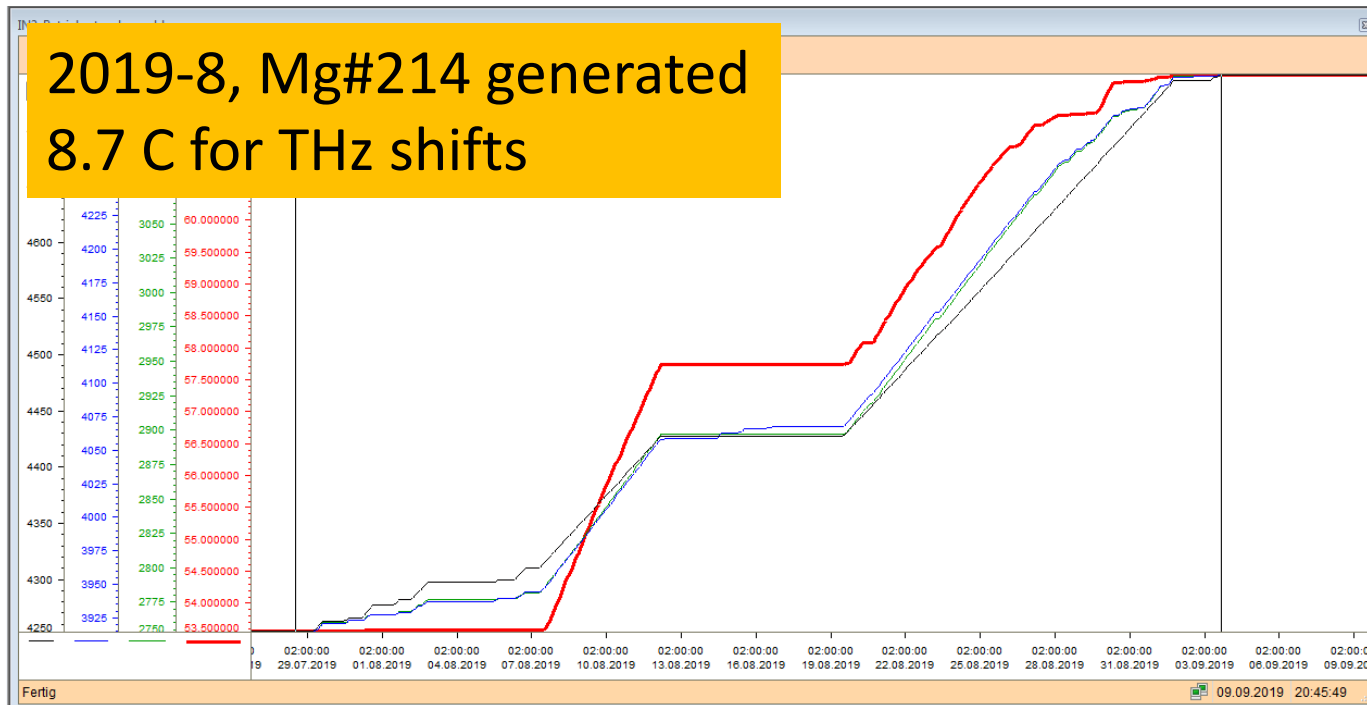
? Thermal emittance



H.J.Qian et al., Appl. Phys. Lett. **97**, 253504 (2010)

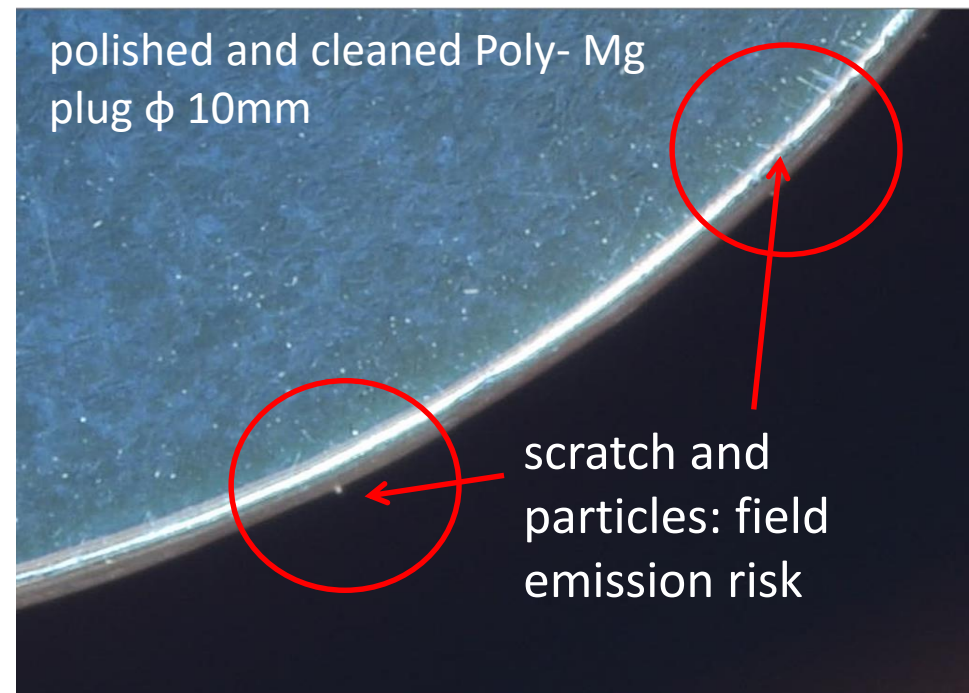
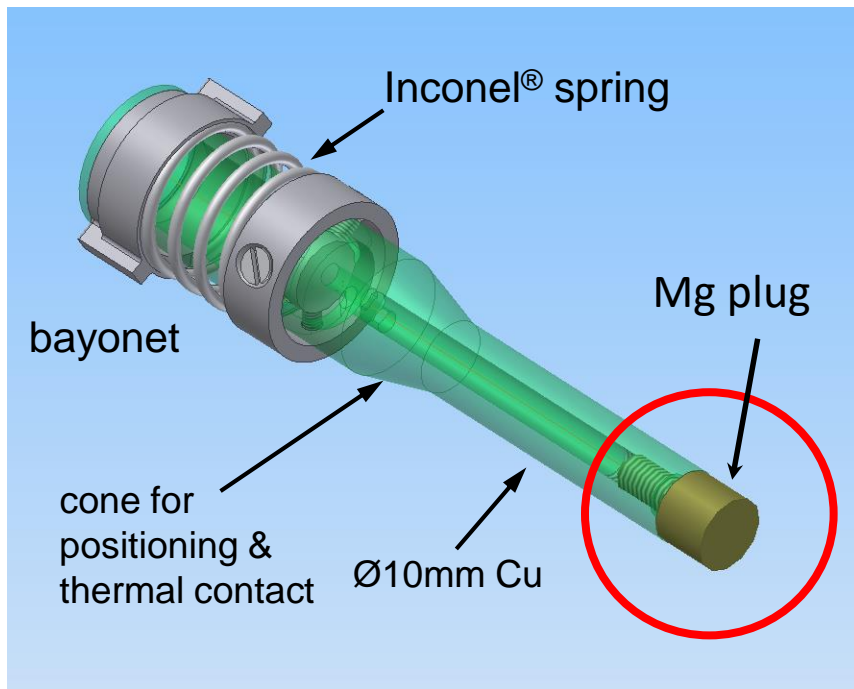
2. Mg photocathodes in SRF gun-II

- ✓ Robust in SRF gun
- ✓ Replaced only due to vacuum issue in injector

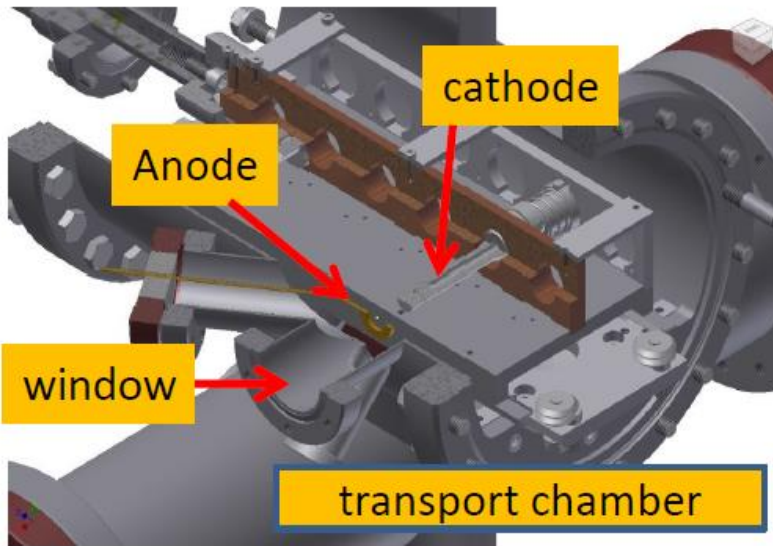
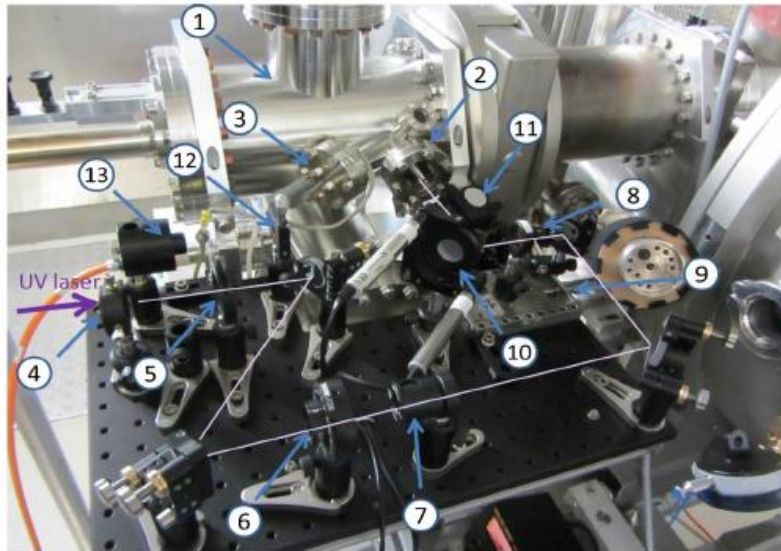


3. ps UV laser cleaning of Mg photocathodes

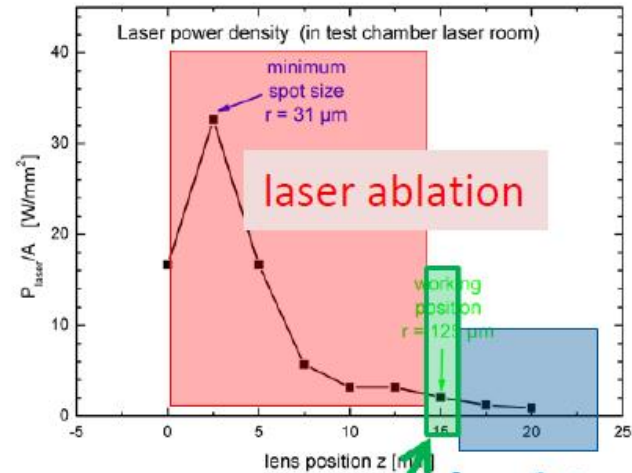
- Steps:**
- Machine bulk plug of Mg (Goodfellow & MaTeck)
 - Optical polishing
 - Remove oxide layer & clean in cleanroom
 - Install in transport chamber and check quality
 - Laser cleaning



3. ps UV laser cleaning of Mg photocathodes

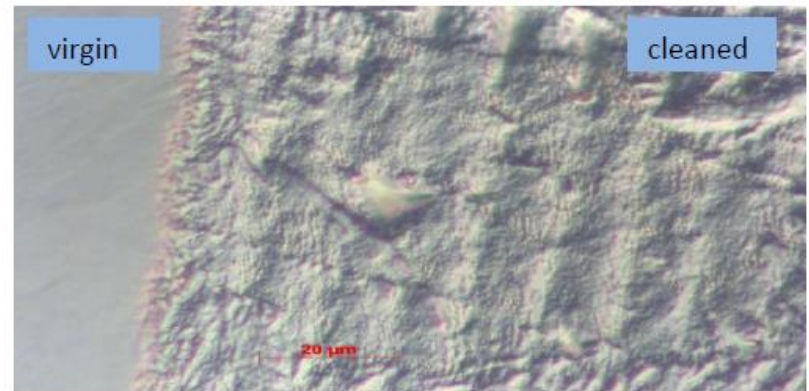


Laser cleaning set-up at transport chamber at SRF gun
using the UV drive laser (100 mW, 100 kHz CW)



low intensity

2.04 W/mm² cleaning

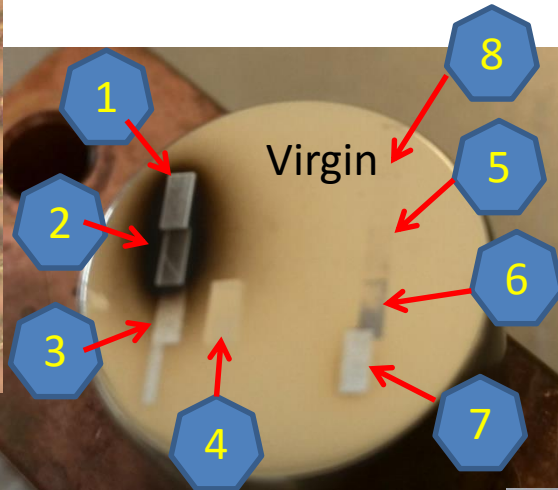


3. ps UV laser cleaning of Mg photocathodes

pos.1, x50, strong ablation, ~ 6 μm deep
low QE

1:recondensed

in test chamber



sample #210

x100, sputtered droplets, high QE but very short life time

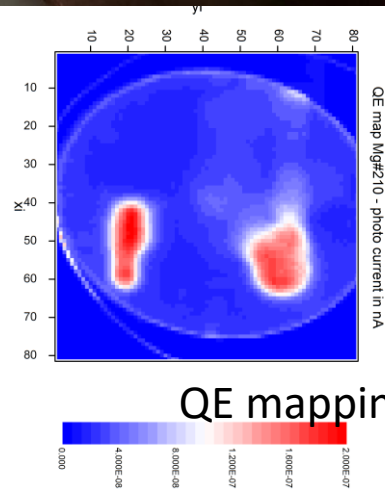
1: sputtered

pos.4, x100
low QE

4: low intensity

pos.7, x100, molten and recondense.
High QE.

7: clean, 2.04 W/mm²

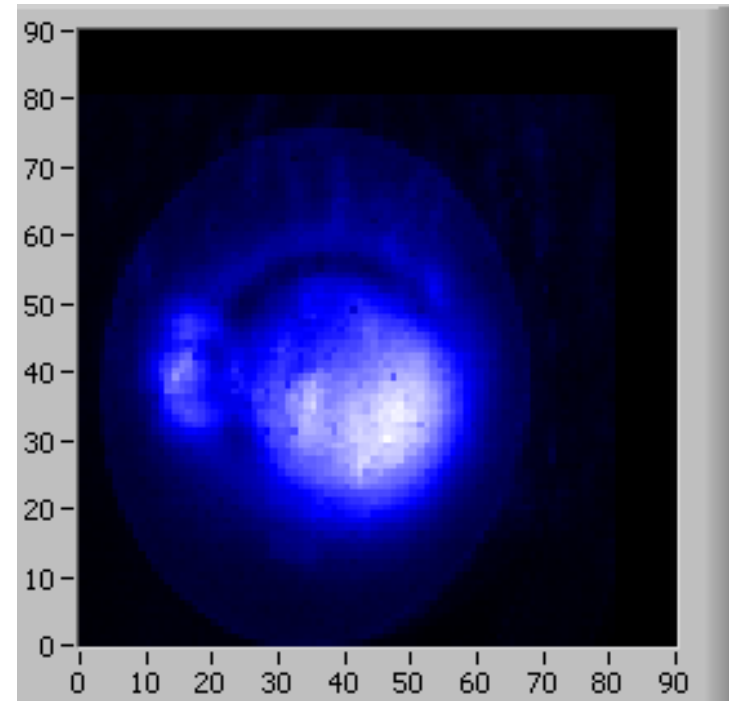


QE mapping

3. ps UV laser cleaning of Mg photocathodes

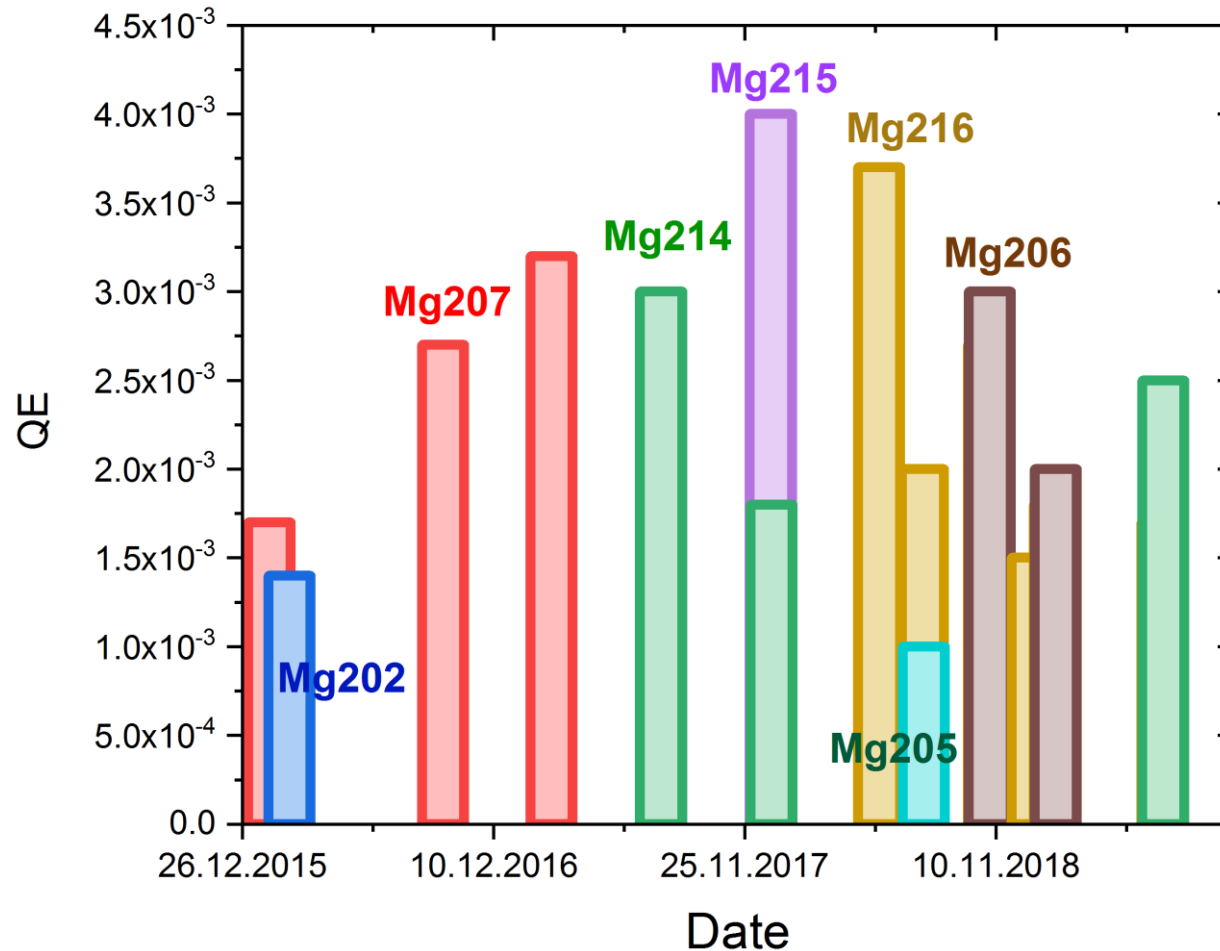


cleaning time: about 2 hours
12 μm x 12 μm step size,
100 ms dwell time



QE mapping
with low laser power

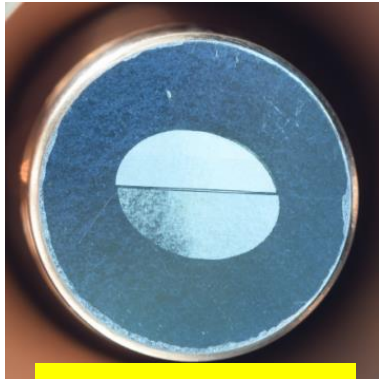
3. ps UV laser cleaning of Mg photocathodes



QE measured in transport chamber with DC bias

3. ps UV laser cleaning of Mg photocathodes

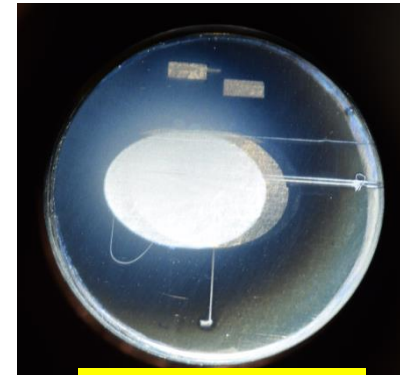
Part of examples



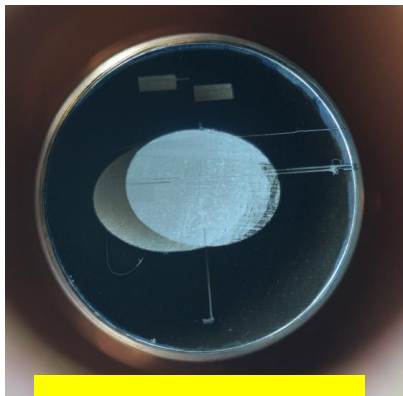
2016.03 Mg #201



2016.11 Mg #207



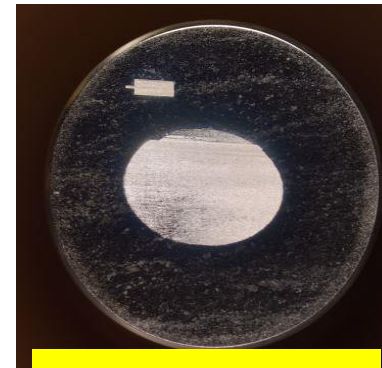
2017.8 - Mg #214



2018.1 - Mg #214



2018.01 - Mg #215

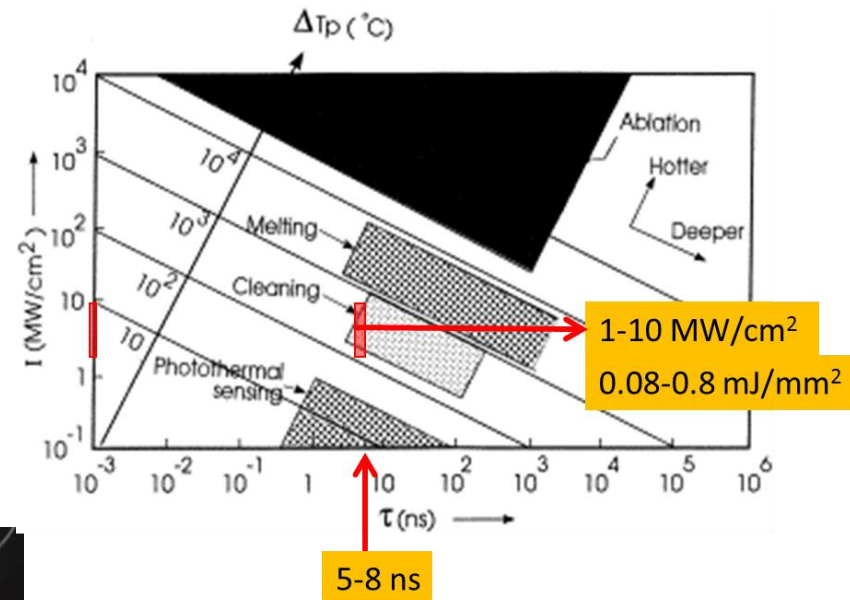


2018.06 - Mg #216

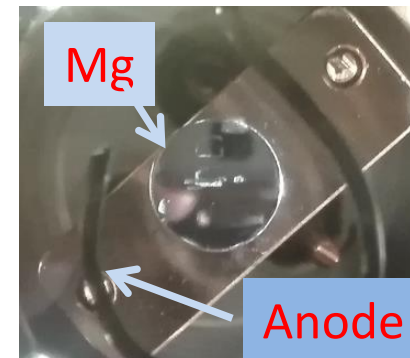
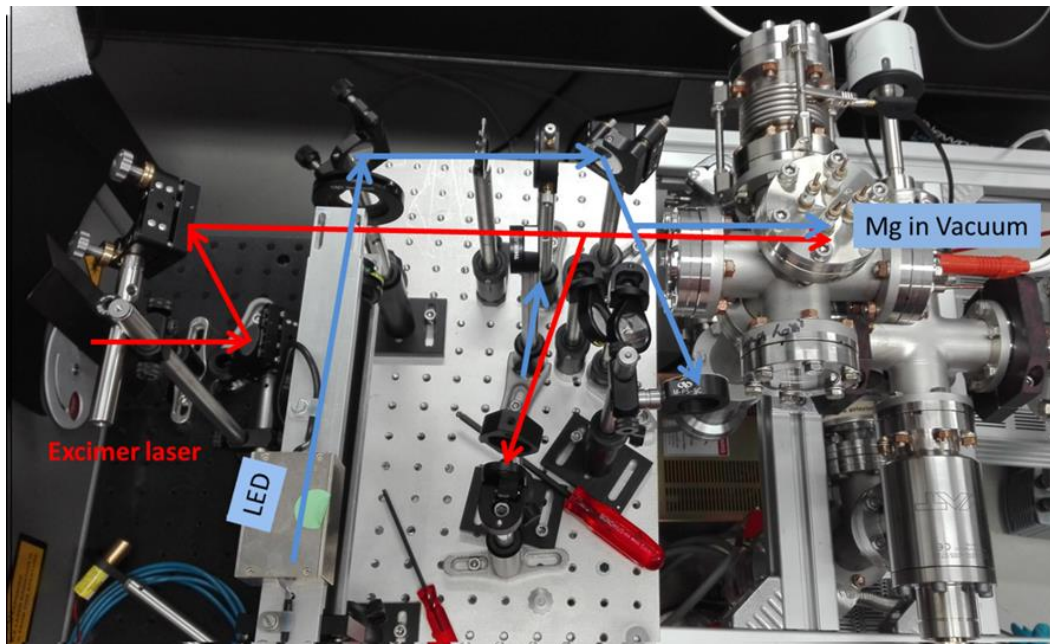
4. Alternative preparation of Mg photocathodes

- *Cleaning with excimer laser*

krF laser, 248nm, 5-8 ns, energy intensity 0.25 -2.5 mJ/mm²



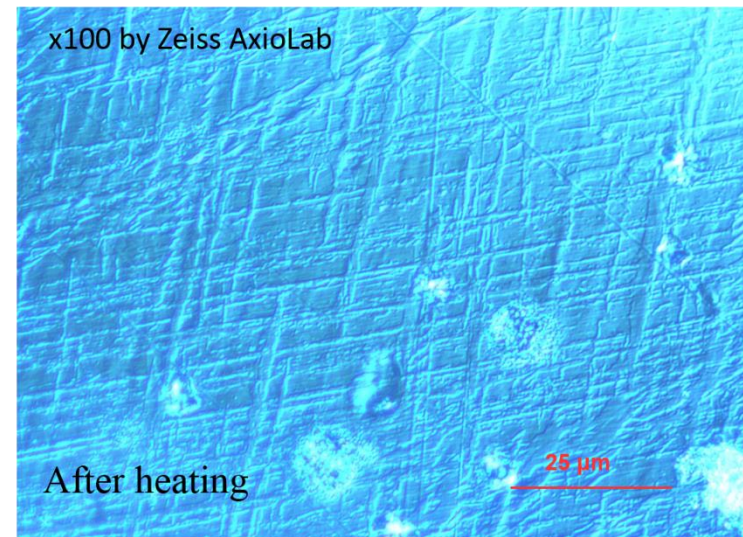
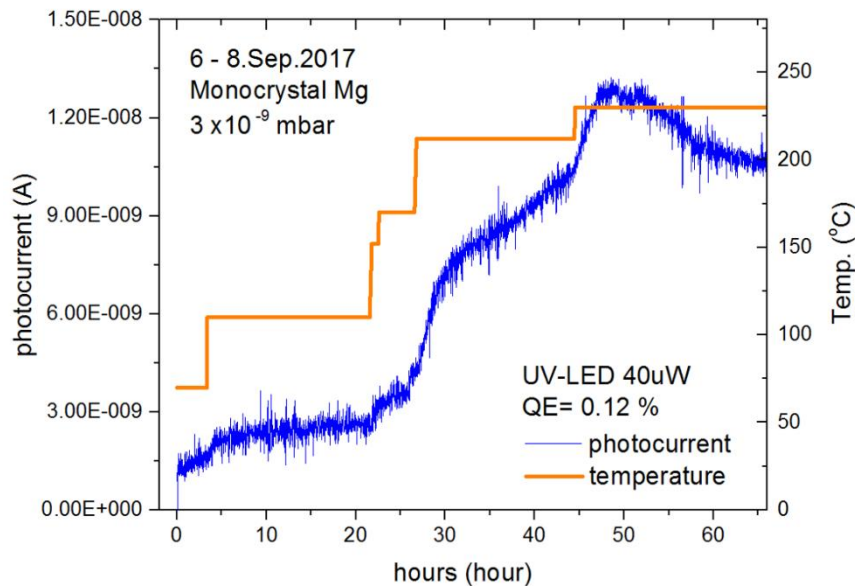
A. C.Tam et al., Applied Surface Science 127-129 (1998) 721-725



going on ...

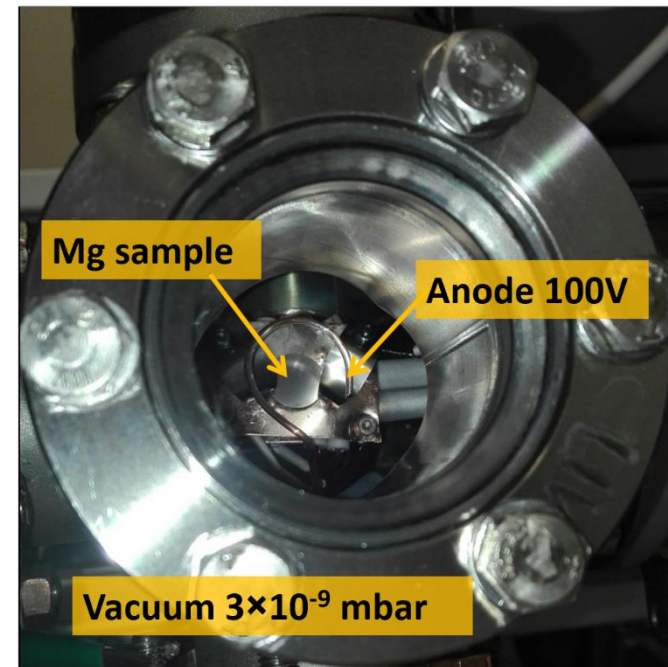
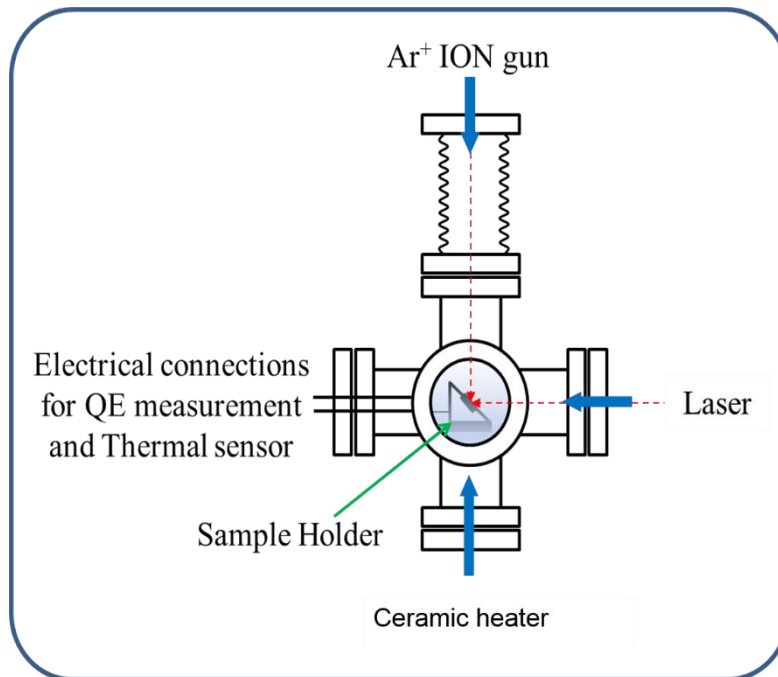
4. Alternative preparation of Mg photocathodes

- *Thermal treatment of Mono-crystal Mg*
 - QE reaches **0.12 %**, smooth surface
 - Repeatable, independent on heating speed
 - Optimal working temperature 220 °C
 - Working mechanism ? Poly-Mg?



4. Alternative preparation of Mg photocathodes

- *Ar⁺ ion bombardment*



5. Summary and outlook

- **Mg photocathodes operate successfully in SRF gun**
 - Mg can reach high QE of $1\sim 4\times 10^{-3}$
 - no multipacting and low dark current (<30 nA)
 - robust
- **Photocathode manipulation is a high risk**
 - careful quality check of cathodes
 - mechanics to avoid particle production
- **Medium / high currents require semiconductor photocathodes**
 - Cs_2Te is still the choice for medium currents (1 mA)
 - suitable substratum
 - new material (GaN)

Thank you for your attention!

Thanks to the ELBE team and our cooperators!



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Influence of Cs₂Te tests to cavity

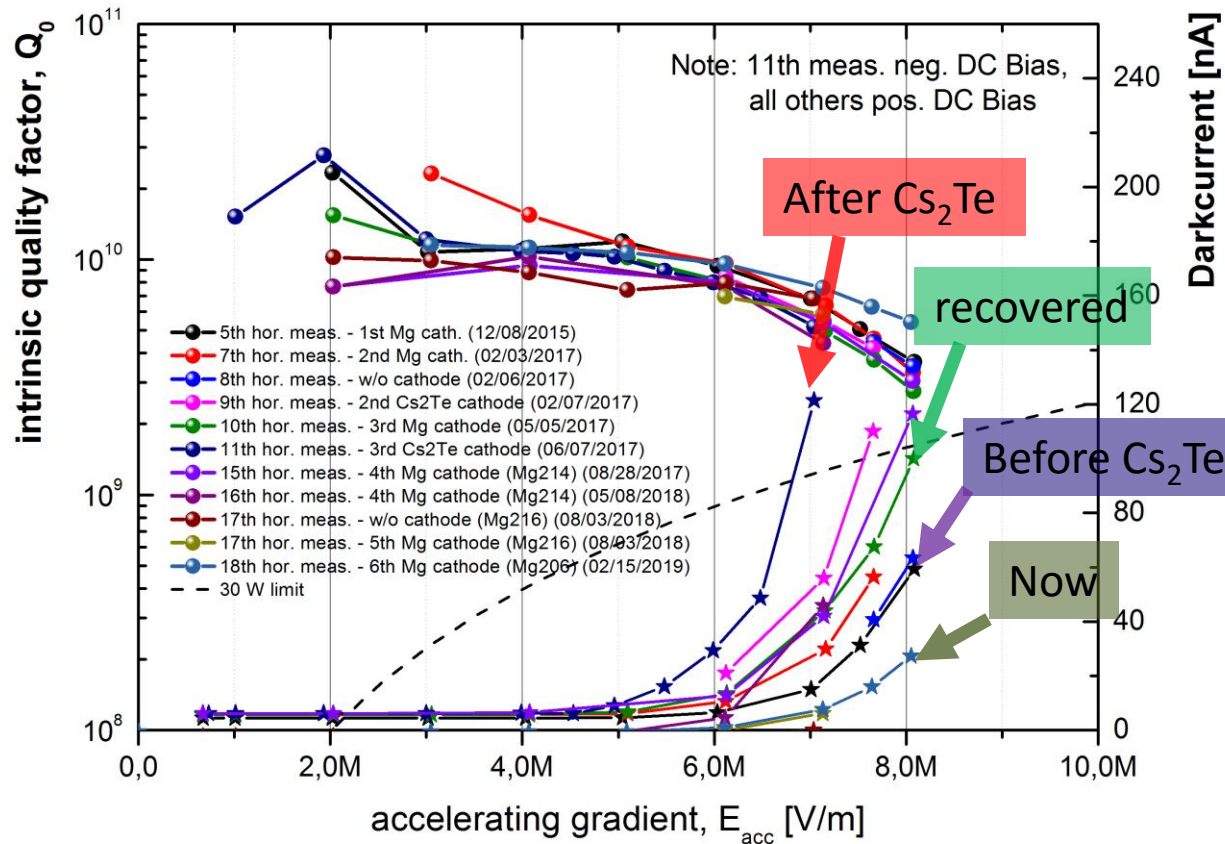


TABLE 3.—VAPOUR PRESSURE OF MAGNESIUM, ZINC AND CADMIUM

temp. °K	vapour pressure, atm		
	MAGNESIUM	ZINC	CADMIUM
298·15	$8\cdot32 \times 10^{-20}$	$4\cdot14 \times 10^{-17}$	$3\cdot92 \times 10^{-14}$
400	$2\cdot03 \times 10^{-13}$	$2\cdot32 \times 10^{-11}$	$3\cdot45 \times 10^{-9}$
500	$1\cdot08 \times 10^{-9}$	$5\cdot19 \times 10^{-8}$	$2\cdot60 \times 10^{-6}$
594	—	—	$1\cdot67 \times 10^{-4}$
600	$3\cdot23 \times 10^{-7}$	$8\cdot64 \times 10^{-6}$	$2\cdot05 \times 10^{-4}$
692·7	—	$2\cdot60 \times 10^{-4}$	—
700	$1\cdot84 \times 10^{-5}$	$3\cdot23 \times 10^{-4}$	—
800	$3\cdot74 \times 10^{-4}$	—	—
900	$3\cdot89 \times 10^{-3}$	—	—
923	$6\cdot15 \times 10^{-3}$	—	—
assumed value of $\Delta H_{v, st}$, cal mole ⁻¹	34,290	30,850	26,540

New project: SRF Gun Lab (start from 2019)

